

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

APPLICANT:	Roman Chistyakov		
SERIAL NO.:	10/553,893	GROUP NO.:	2821
FILING DATE:	October 21, 2005	EXAMINER:	Haissa Philogene
TITLE:	HIGH DENSITY PLASMA SOURCE		

Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

**RESPONSE**

Sir or Madam:

The following remarks are responsive to the Office Action mailed on March 7, 2008 in the above-identified patent application. Consideration of the following remarks, and allowance of the claims, as presented, is respectfully requested. Authorization to charge Attorney's charge card for the Statutory Disclaimer fees and any other proper fees is given in the EFS-Web filing submission papers.

Remarks begin on page 2 of this paper.